

Beam test of a small MICROME GAS DH CAL prototype

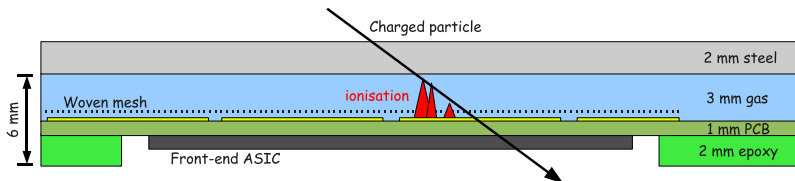
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September 16, 2009

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- Micromegas for a DHCAL:
 - fast, radiation hard, good ageing properties, robust, large area, high gas gain, spark proof, standard gas mixture (Ar , $i\text{C}_4\text{H}_{10}$, CO_2)
 - small avalanche charge \rightarrow sensitive front-end electronics

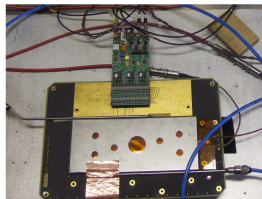
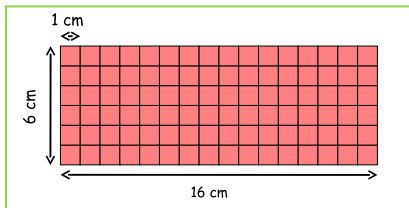


- R&D activities at LAPP:
 - fabrication and test of thin detector of large area (up to 1 m^2)
 - front-end chips used: GASSIPLEX, HARDROC, DIRAC
 - simulation, DAQ (DIF), mechanics (SiD), electronics (DIRAC)

GASSIPLEX readout chambers

- Chamber geometry

- Anode PCB with 1 cm² anode pads (96 and 384 pad PCBs)
- Bulk MICROMEAS: 128 μm gap mesh laminated on PCB
- Plastic frame and steel cover define a 3 mm drift gap

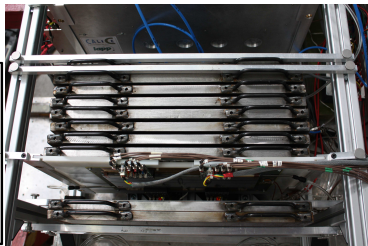
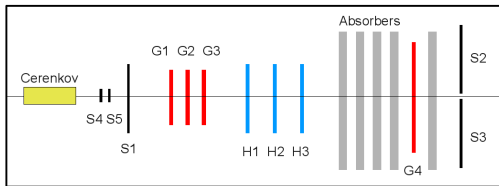


- Readout electronics

- GASSIPLEX chip: 16 channels with preamplifier and shaper
- 4 boards with 6 chip each, multiplexed output
- Digitization by 10 bit ADCs connected to a PC
- Ar/*i*C₄H₁₀ 95/5: high gains ($20 \cdot 10^3$) at moderate voltages (≤ 450 V)

Beam test setup

- CERN/PS beam (T10 zone): e^\pm , π^\pm , p^\pm up to 10 GeV
- Chambers:
 - 3 $6 \times 16 \text{ cm}^2$ chambers with GASSIPLEX readout (G_1 – G_3)
 - 1 $12 \times 32 \text{ cm}^2$ chamber with GASSIPLEX readout (G_4)



- Trigger:
 - 3 $8 \times 32 \text{ cm}^2$ scintillators for chamber area scans (S_1 – S_3)
 - 2 crossed $2 \times 4 \text{ cm}^2$ sc. for shower profile studies (S_4, S_5)
 - Cerenkov counter to tag 2 GeV electrons/positrons

Energy measurement principle

- The number of ADC counts N measured on a given channel relates to the energy deposited in the gas ϵ above the corresponding pad:

$$N = \frac{q_e G S}{W} \epsilon$$

- Summing over each hit ($t = 3$ fC), the energy deposit is:

$$\xi = \sum_i \epsilon_i = \frac{W}{q_e} \sum_i \frac{N_i}{G_i S_i}$$

- Using values averaged over all channels:

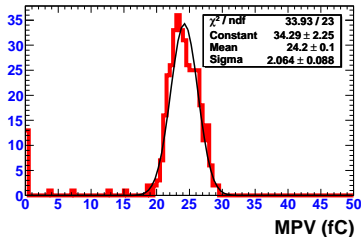
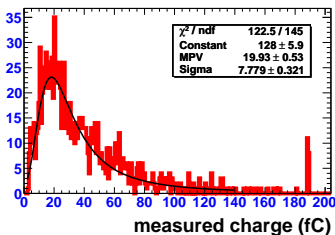
$$\xi = \frac{W}{q_e} \frac{1}{\overline{G S}} \sum_i \frac{\overline{G S}}{\overline{d}} \frac{d_i}{G_i S_i} N_i = \frac{W}{q_e} \frac{1}{\overline{G S}} \sum_i a_i N_i$$

- However, G_i and d_i are not known

→ deduce a_i from the signal distribution on each pad

Channel inter-calibration

- Measure signal distribution on each pad:
 - Move chamber across the beam, trigger from large scintillators
 - Insure that all charge is collected on one pad \rightarrow event with single hit
 - Collect between 200 and 500 events per pad



- Inter-calibration:
 - Adjust Landau function on measured distribution \rightarrow MPV m_i
 - Coefficient a_i given by m_i / \bar{m}
 - Correction applied as: $N_i \rightarrow N_i \cdot (1 \pm |1 - m_i / \bar{m}|)$

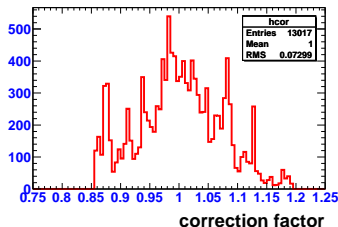
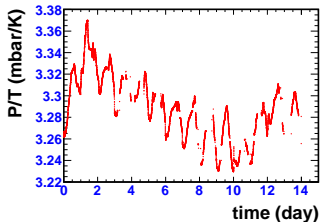
Pressure temperature corrections

- Pressure and temperature variations impact on the gas gain.
 - Writing V the mesh voltage and (A,B) two parameters:

$$G(V) = \exp\left(\frac{APg}{T} \exp\left(-\frac{BPg}{TV}\right)\right)$$

- The gain relative sensitivity to P, T variations can be predicted:

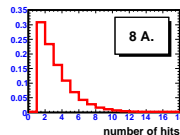
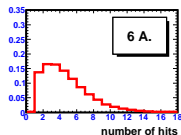
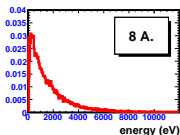
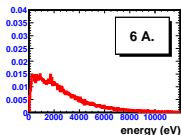
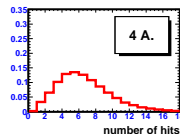
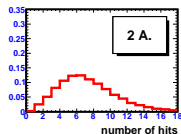
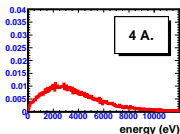
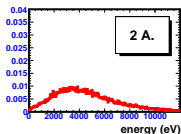
$$C_{P/T} = \left(Ag - \frac{ABPg^2}{TV}\right) \exp\left(-\frac{BPg}{TV}\right)$$



- Correction applied as: $N \rightarrow N \cdot (1 - C_{P/T} \Delta(P/T))$

Energy and Hit distribution of electron showers

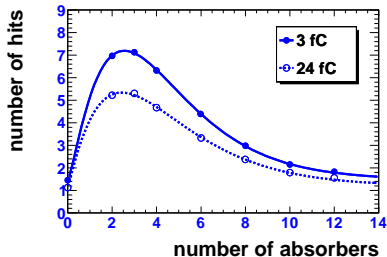
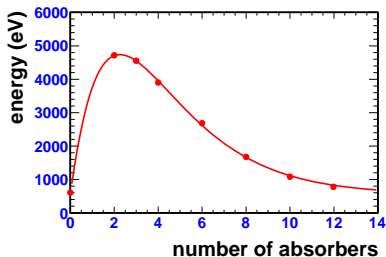
- Record about $40 \cdot 10^3$ triggers for a given number of absorbers
- Insure that a track has traversed the small chambers:
 - request at least one hit in two of the three chambers
 - request aligned hits (centered at the beam profile maximum ± 1 pad)
 - trigger from small crossed scintillators
- Apply inter-calibration and P, T correction



Longitudinal profile of electron showers

- Plot distribution mean versus number of absorber n
 - Adjust 3 parameters on the trend:

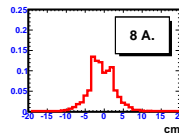
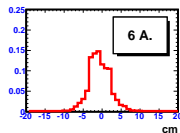
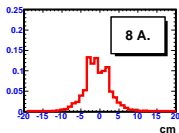
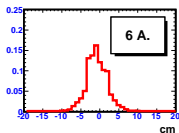
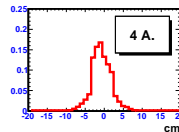
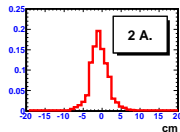
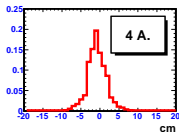
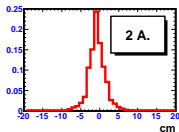
$$f(n) = p_0 n^{p_1} \exp(-p_2 n)$$



- Small effect of the threshold:
 - Maximum of f_{hit} reached at a slightly larger depth
 - Most secondaries traverse one pad at the beginning of the shower

Energy and hit distribution of electrons

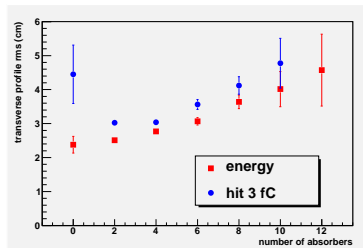
- Insure that a track has traversed the small chambers:
 - request at least one hit in two of the three chambers
- Calculate the distance between pad and shower axis:
 - axis varies from one shower to the other
 - request aligned hits (centered at the beam profile maximum)



- Energy distribution (left) slightly more peaked with a smaller RMS

Transverse profile of electrons

- Difference between energy and hit profile
 - Hit distribution is flatter at the beginning of the shower
 - Can be seen as a larger RMS



- Micromegas behaviour in 2 GeV electron:
 - Stable and high gain during test period (a few HV trips over 12 days)
 - P, T variations can be corrected for, or HV adjusted accordingly
- Energy and number of hit distributions:
 - Show a similar trend with the number of absorber
 - Longitudinal hit distribution maximum reached slightly deeper
 - Transverse hit distribution shows larger RMS at first shower stages
- Future plans
 - Comparison with simulation
 - Take data at different energies at next beam test (next week)